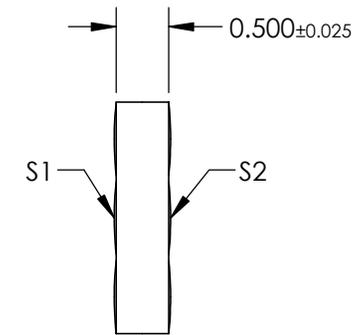
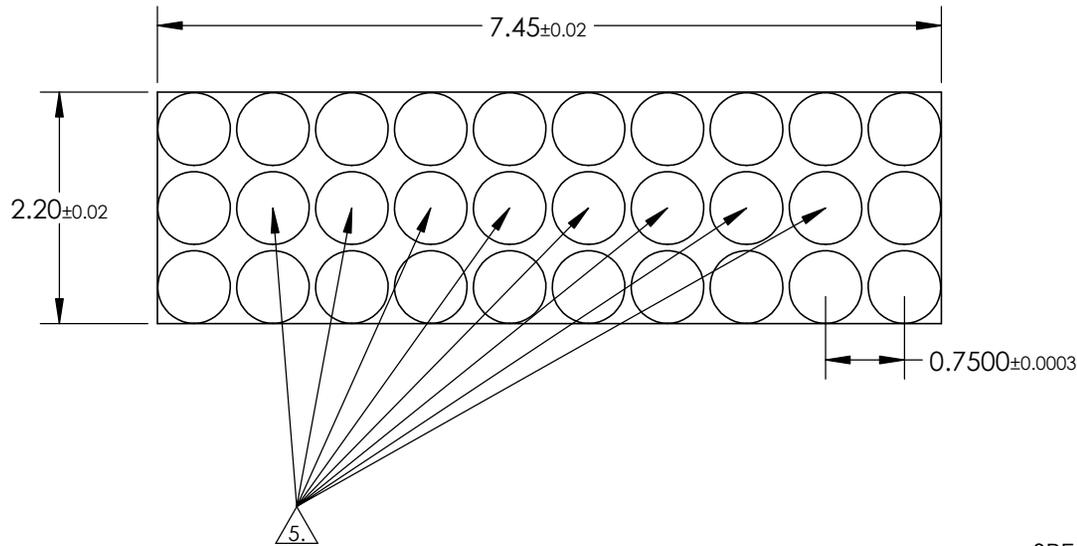
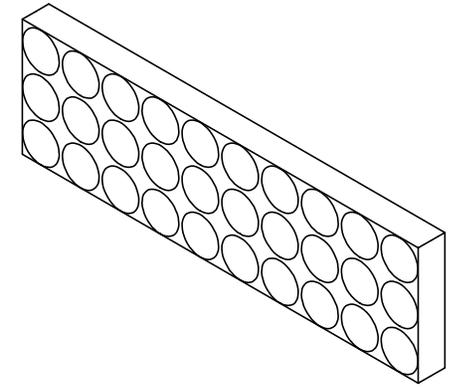


NOTES:

1. SUBSTRATE:  
Silicon
2. COATING (APPLY ACROSS COATING APERTURE):  
S1 & S2: R(AVG)  $\leq 0.5\%$  @ 1250 - 1620
3. WORKING DISTANCE (mm):  
1.202
4. MODE FIELD DIAMETER (mm):  
Source: 0.0092  
Target: 0.25

5. ACTIVE LENSES CENTERED ON SUBSTRATE

6. ROHS: COMPLIANT



SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE  
DIMENSIONS ARE FOR REFERENCE ONLY

**FOR INFORMATION ONLY:  
DO NOT MANUFACTURE  
PARTS TO THIS DRAWING**

**EO**® **Edmund Optics**®

THIRD ANGLE PROJECTION		TITLE	7.45 x 2.20mm, 3.378 ROC, 750µm Pitch, Silicon, 1 x 8 Linear Microlens Array	
ALL DIMS IN	mm	DWG NO	21181	SHEET 1 OF 1